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OPEN Author Correction: Holographic Writing of Ink-Based Phase **Conjugate Nanostructures** via Laser Ablation

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Correction to: Scientific Reports https://doi.org/10.1038/s41598-017-10790-4, published online 06 September 2017

In the original version of this Article, the authors re-used a paragraph in the Results and Discussion section without a proper attribution to the source (ref. 40).

In the Results and Discussion section, under subheading 'Phase Conjugate Nanostructure Recording':

"For materials exposed to nanosecond laser pulses, the principal mechanisms of material removal are vaporization and phase explosion. These both phenomena are thermal in nature, as the pulse duration is greater than the phonon-electron relaxation time of the target³⁷. When exposed to nanosecond laser pulses of high intensity, the surface of target materials may be heated above the equilibrium boiling temperature toward the critical temperature, T_c. The emission of particles by normal vaporization is a function of the surface temperature and equilibrium vapour pressure, but is not accompanied by a temperature threshold³⁸. With sufficient laser fluence, the target surface temperature may reach 0.8 T_{c} , where a dielectric transition takes place and the electrical and thermal conductivities fall by several orders of magnitude³⁹. During this process, the surface layer becomes partially transparent and large fluctuations in density occur. With additional absorption of energy from the laser beam, the target surface temperature approaches $0.9 T_c$ and the nucleation rate of vapor bubbles rises dramatically, leading to the ejection of liquid droplets and vapors by explosive boiling, or phase explosion⁴⁰."

now reads:

"For materials exposed to nanosecond laser pulses, the principal mechanisms of material removal are vaporization and phase explosion³⁷⁻³⁹, which are discussed in detail by Lutey et al.⁴⁰

The authors apologize for the error.



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